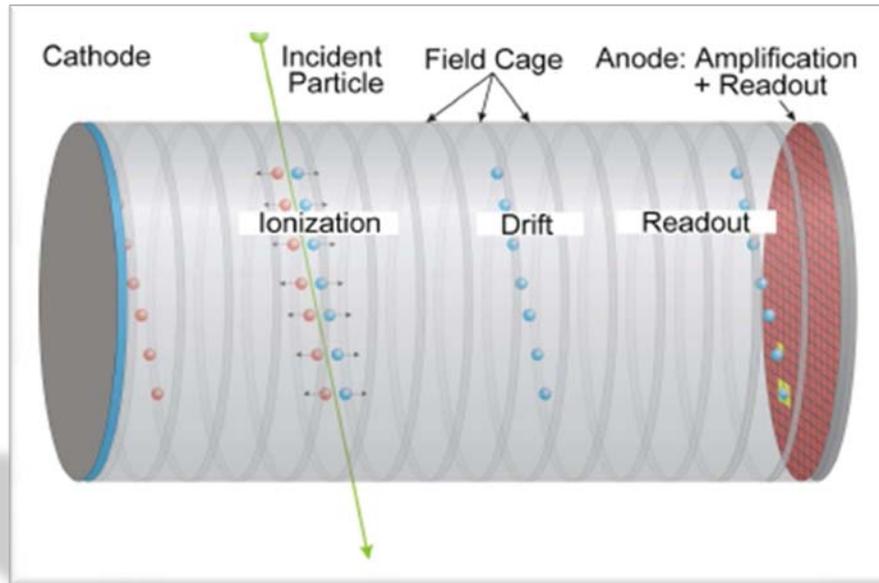




A New GEM Module for the LPTPC

By

Stefano Caiazza



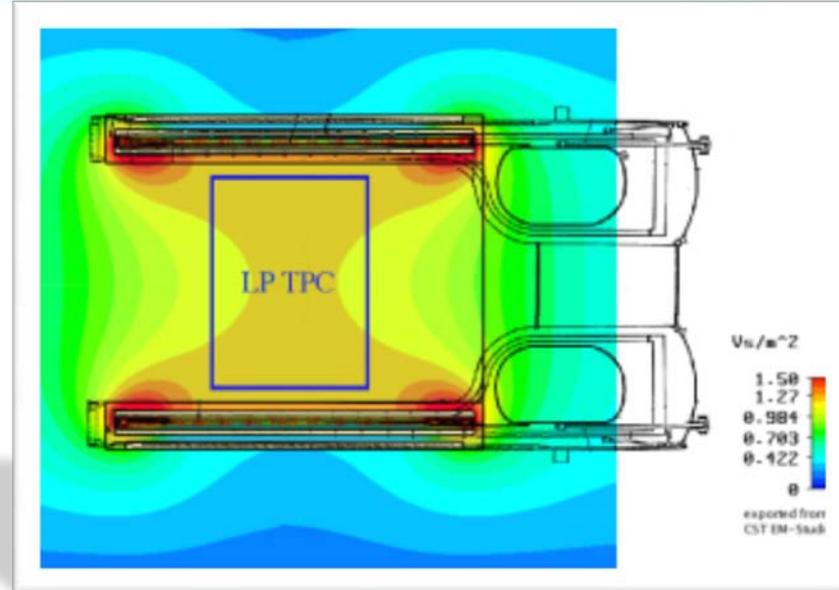
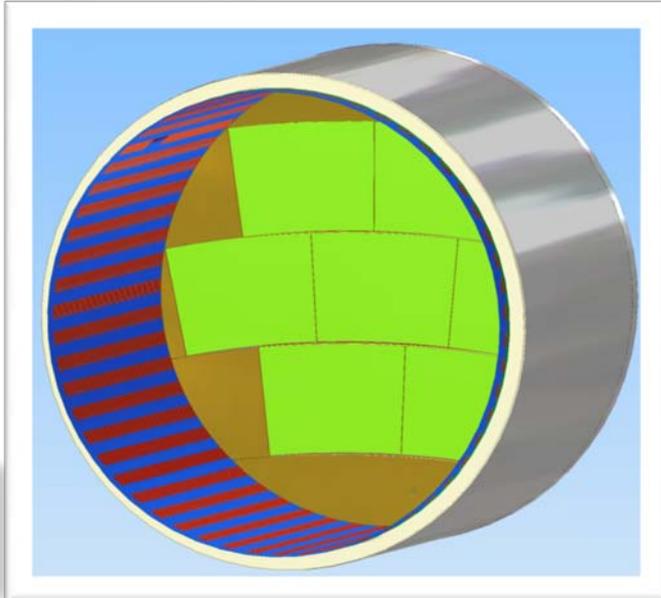
Gas Tight Container where ionization occurs

Well known Electric and Magnetic Fields

- To control the drifting inside the chamber
- The most simple configuration is with homogenous fields perpendicular to the readout system

Amplification and Readout system

- Reconstruct the 3D position of the ionization clusters

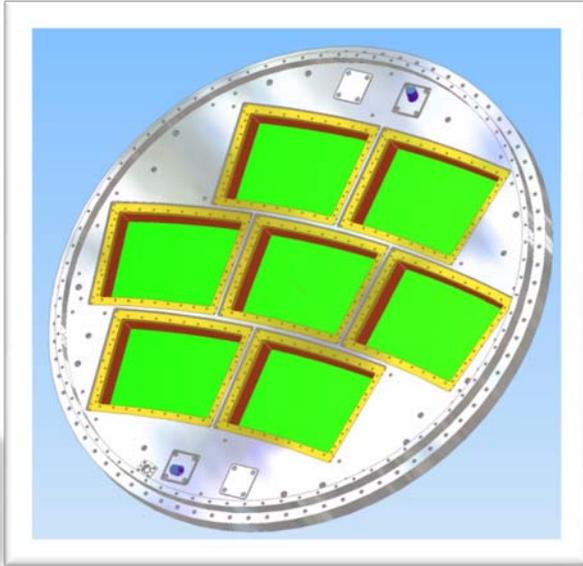


Field Cage designed by Peter Schade

- 60 cm drift length
- 72 cm inner diameter
- Designed to fit inside PCMAG

PCMAG

- Superconductive Magnet with standalone LHe Cooling and low mass coil
- 1 Tesla Magnetic Field
- Supplied by KEK

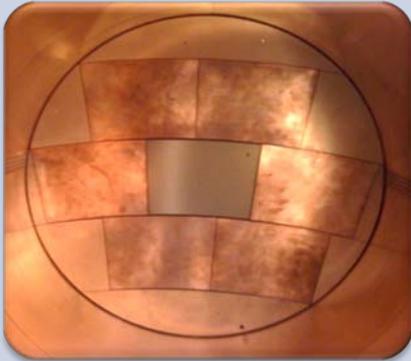


Endplate

- Designed by Dan Peterson at Cornell
- Aluminum Alloy
- Accomodates seven identically shaped modules

The Modules

- Cornerstone shape
- 22 cm wide (average value) – Max width 24 cm
- 17 cm high



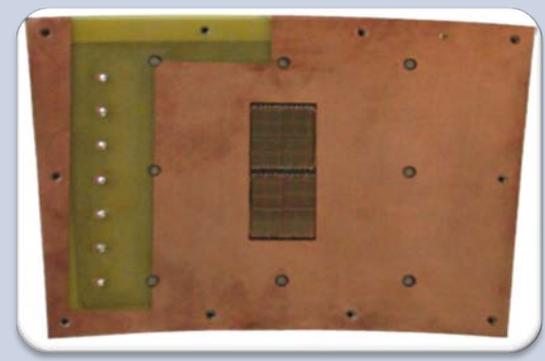
Micromegas

- Built at Saclay
- Pad Readout
- Multiple versions with naked or coated pads
- Readout with T2K Electronics



Asian GEM

- Built in Japan and China
- Japanese produced GEM
- Pad Readout with Altro Electronics
- GRP Frame on the upper and lower side



Bonn GEM

- 10X10 cm Standard CERN GEM
- Pad Readout with Altro Electronics
- Pixel readout with integrated electronics

Desy Module – Our Goals

Maximum Sensitive Area

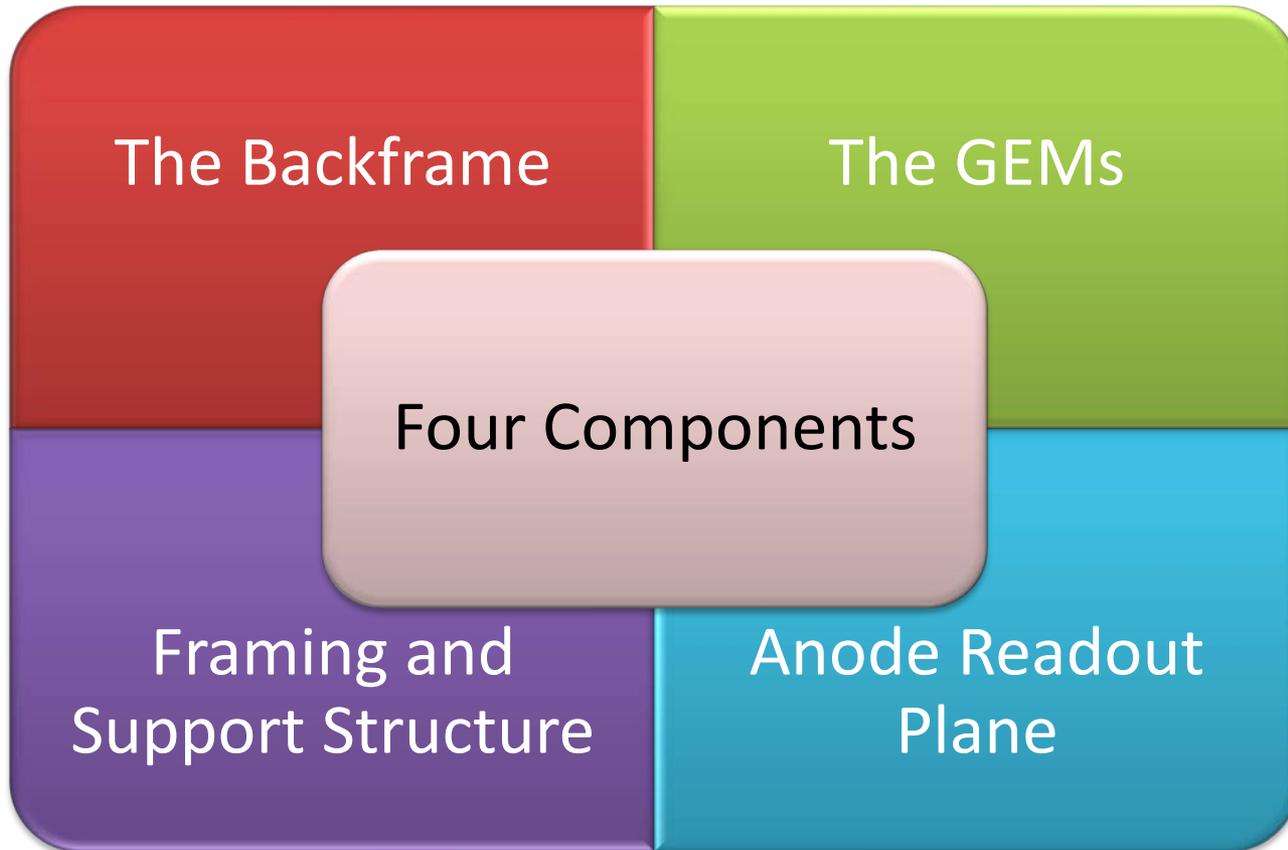
- We will need to use a custom designed GEM

Gain Uniformity between 5/10%

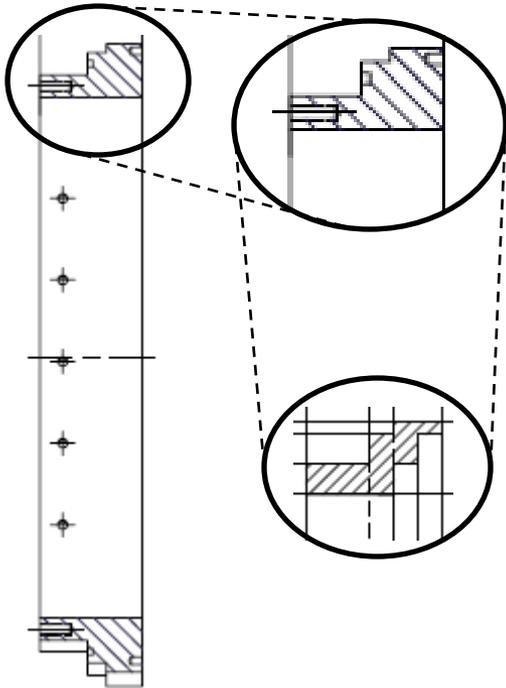
- We need to ensure a good flatness of the GEM
- The uniformity may be improved with calibration
- Good dE/dx resolution

Spatial resolution under 100 μm

- Small pad size



The new backframe: Design



Goal

- To increase the available space on the connector side of the readout plane

Solution

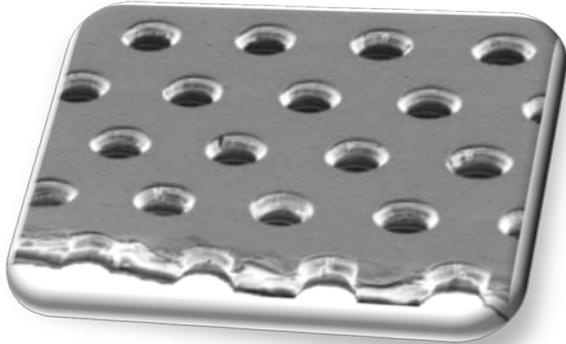
- Remove part of the backframe structure
- The element which has been thinned is only supporting the pad plane
- We don't expect negative effects from this upgrade

Production

- The production of the backframe will be performed at the University of Hamburg workshop

Materials

- The material chosen is an aluminum alloy called AlMg4,5Mn (Dogal 5080)



Custom GEM

- Specifically designed to get the maximum sensitive area

Produced by CERN

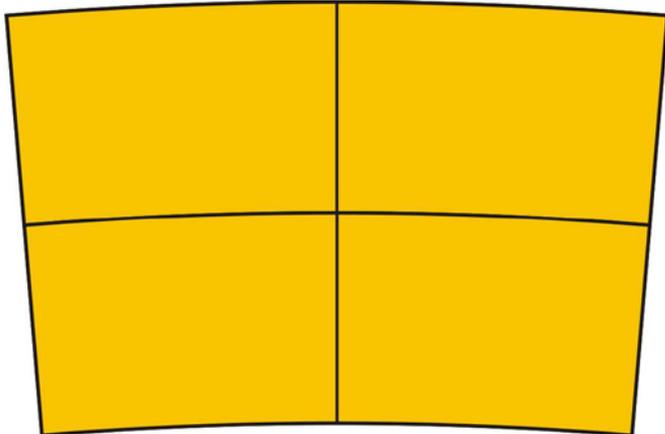
- 50 μm kapton foil
- Chemical etching

Standard hole size and pitch

- 70 μm hole size
- 140 μm hole pitch

4-fold electrode segmentation

- The surface of the GEM must be segmented to reduce the damage caused by electrical discharges



Frame and Support System: Issues



Standard GEM frames made of GRP (Glass Reinforced Plastic)

- The width of the frame is about 1 cm
- No supported areas inside the frame

Decrease the size of the unsupported areas

- Gain uniformity limited by the GEM sagging
- To reduce the sagging we must limit the unsupported areas of the GEM

Increase the sensitive area

- Sensitive area limited by the presence of supporting materials
- To increase the sensitive area we need to reduce the width of the framing and supporting structure

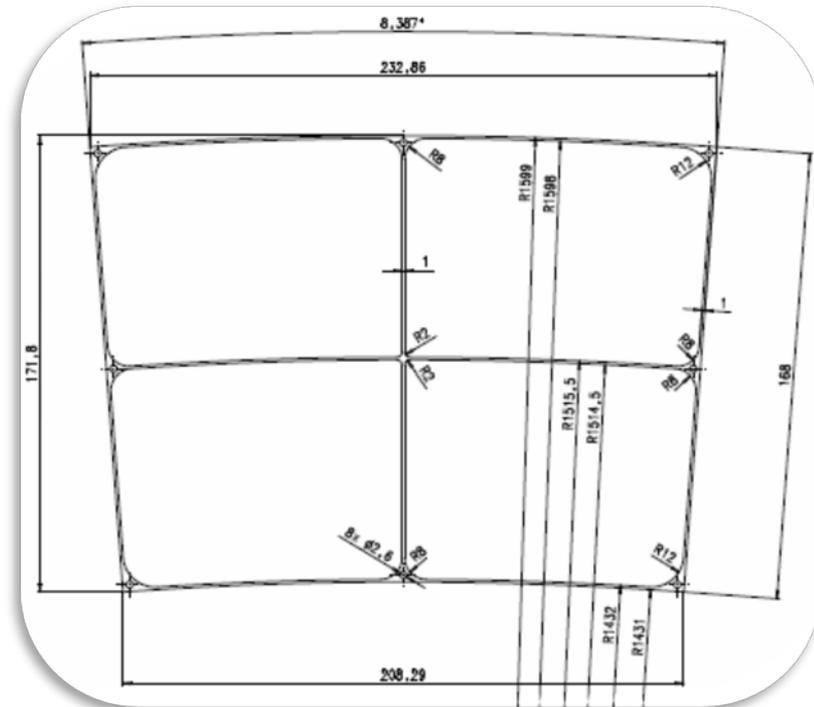
What we need:

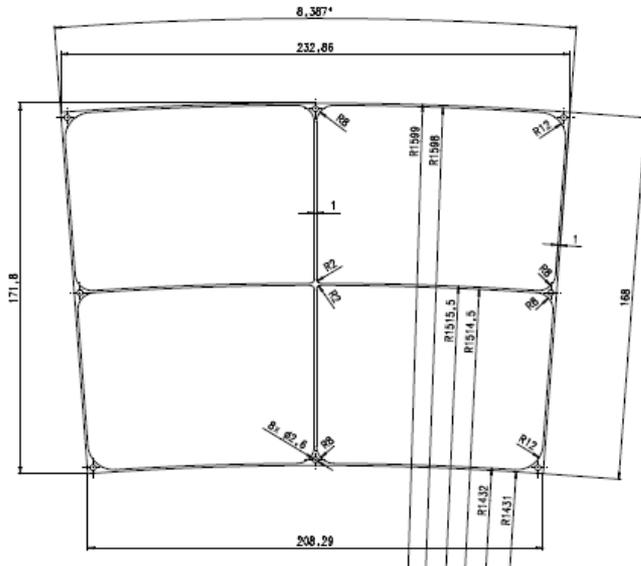
- Insulating material stiff GRP
- The material should be machinable at thicknesses smaller than 1 cm



What we choose:

- Alumina Ceramics
- Almost 4 times stiffer than GRP
- May be machined with widths up to 0.3 mm





Modular structure

- Every GEM can be separately framed
- The framed GEM can be piled up to form the stack using “ungemmed” frames as spacers
- There are 8 strong points for the mounting and aligning of the support structure

1.0 mm width

- The external frame and the internal grid structure are 1.0 mm wide
- Smaller widths were considered and discarded because of insufficient resistance

Grid patterns

- Many grid patterns have been considered
- The one shown has been selected for the first tests

Production

- We are in contact with two firms and evaluating their proposals

The GEM Stack: Features

Three GEM + possible gate

- Three GEM stack
- Optional fourth module (gating)
- The gate may be both GEM or wire based

Time resolution

- Small induction gap \rightarrow better time resolution
- Time resolution depends also on the longitudinal diffusion during drift

Defocussing

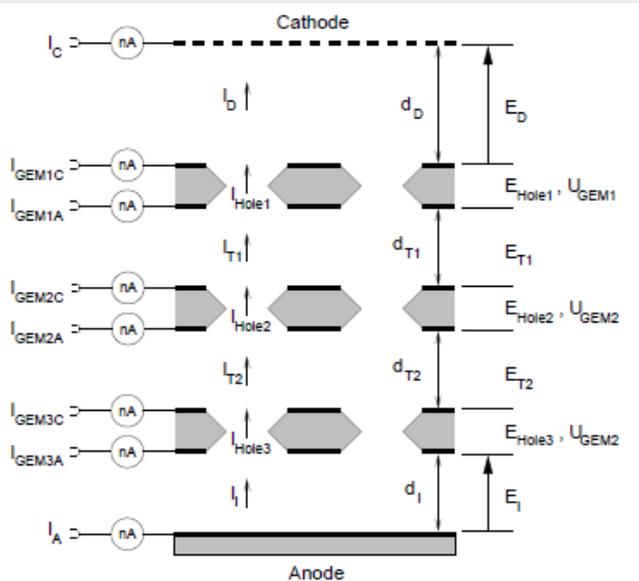
- Gap's size and fields influence the defocussing of the electron clouds
- The defocussing and the pad size influence the point resolution

Ion backdrift

- Influenced by the fields and of the potential across the GEMs

Gap size and field intensities not yet finalized

- Simulation and calculation will be performed in the near future to find the best compromise

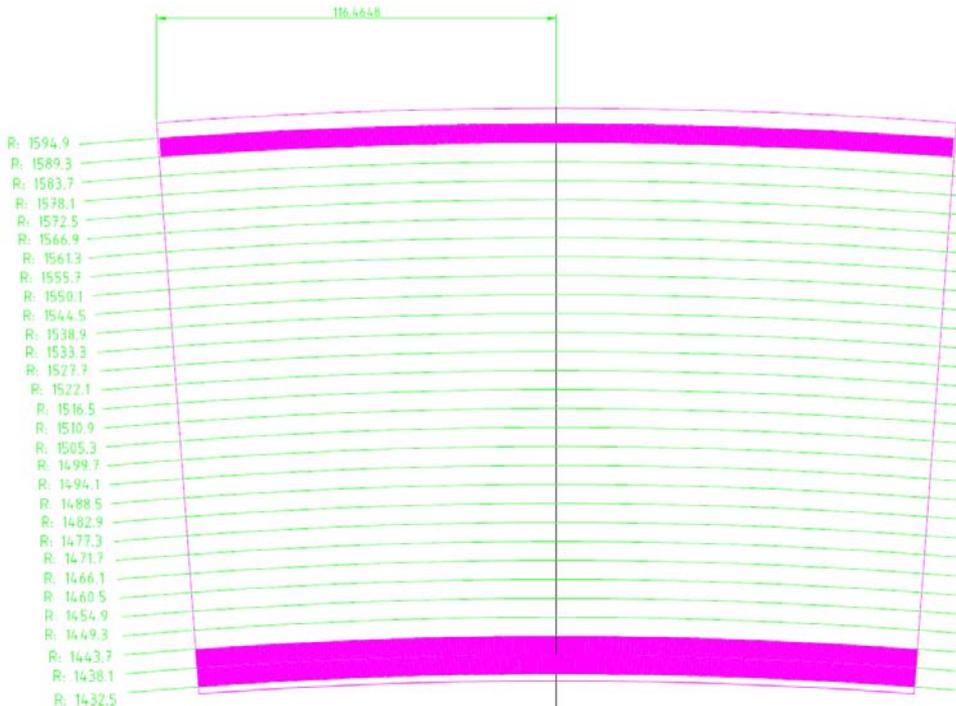


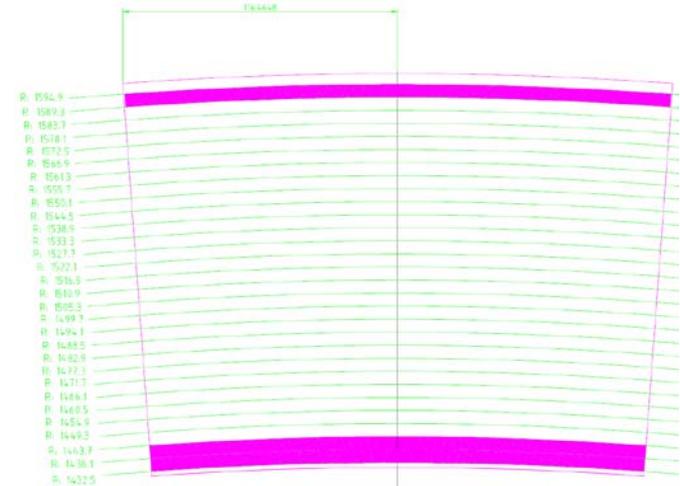
Structural Features

- Ensure gas tightness
- Support the GEM stack
- Provide power to the GEM stack

Readout Features

- Pad readout
- Maximum possible sensitive area
- Readout by ALTRO electronics





In collaboration with Bonn University

- The design is still in his infancy
- Using the data acquired testing the Bonn GEM module

Pad size

- $(1.1 \div 1.25) \times (5.6 \div 5.8)$ mm
- 28 rows
- Row gaps aligned with the GEM segmentation gap

GEM Power supply

- Supplied from power pads on the PCB itself
- Using the ceramic structure to separate the power from the readout pads

Gain Calibration

- Beam calibration
- Laser calibration
- Radioactive source calibration

Gate efficiency

- Confront the efficiency of GEM and wire gates

Ion Backdrift Measurement

- We need the equipment to perform this measurements on the LP

Module Backframe

- First design ready
- Production of the first prototype began

Ceramic Framing

- First design ready
- Evaluating producer's offers

GEMs

- First design ready
- Getting feedback from CERN to update this design

Anode Readout Plane

- Design just beginning

Other ideas

- Compare gating modules
- Test the gain homogeneity of the modules
- Measure the ion backdrift in the TPC